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Enhancement of basal plane electrocatalytic hydrogen evolution activity via joint utilization of trivial and non-trivial surface states

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ABSTRACT

Transition metal dichalcogenide semiconductors, particularly MoS₂, are known as promising alternative non-precious hydrogen evolution reaction (HER) electrocatalysts to high-cost Pt. However, their performance is strongly limited by the poor conductivity and lack of active sites in the basal plane. Therefore, it is desirable to find alternatives with active basal plane sites or develop facile strategies to optimize the inert basal plane. In this work, we study the HER over topological semimetal Nb₂S₂C based on its basal plane. We report the first successful activation and optimization of the basal plane of Nb₂S₂C by synergistic using trivial surface states (SSs) and nontrivial topological surface states (TSSs). We find that the binding strength towards hydrogen adsorption of the easily cleaved sulfur(*S*)-terminated Nb₂S₂C surface can be stronger than that of 2H-MoS₂, attributing to the presence of trivial SSs and nontrivial TSSs in Nb₂S₂C. By creating S vacancy on the basal plane, the binding strength towards hydrogen adsorption can be greatly optimized. The TSSs together with dangling-bonds reduce the Gibbs free energy to 0.31 eV, close to the peak of the volcano plot. This study provides a promising strategy for the joint utilization of the basal plane trivial SSs and TSSs for the HER.

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1. Introduction

 H_2 is one of the most important next-generation energy carrier candidates owing to its high-energy density and environmental friendliness. Electrochemical water splitting has been considered one of the most effective ways for H_2 production. Moreover, it has been established that the catalytic activity of transition metal surfaces follows well-defined volcano plots, and precious-metal-based materials, such as Pt and Pt-based materials, present the most favorable Gibbs free energy (ΔG_{H^*}) for hydrogen (H) binding [1–3]. However, the scarcity and high-cost of precious metals greatly limit their practical applications. Because of the natural characteristics of active, earth-abundant, and inexpensive, layered materials, such as MoS₂, they have been considered as promising electrocatalyst alternatives to precious metals [4–9]. However, most layered materials present shortcomings. For example, semiconducting 2H-MoS₂, the most stable phase, shows poor electrical conductivity, which

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E-mail addresses: Thomas.Heine@tu-dresden.de (T. Heine), Claudia.Felser@cpfs.mpg.de (C. Felser), Yan.Sun@cpfs.mpg.de (Y. Sun). hinders the charge-transfer kinetics. In addition, its surface sulfur (S) atoms are chemically saturated which leads to weak interactions with H. It was confirmed that the chemically active sites originate only from the metallic edges, and the large surface area is catalytically inert [10,11]. Various techniques, such as phase engineering [12,13], defect engineering [14–18], strain engineering [19], and chemical doping [20,21] have been developed to overcome this limitation and activate the inert basal plane of MOS_2 .

Recently, it was demonstrated that the metallic topological surface states (TSSs) near the Fermi level were effective for facilitating the charge-transfer kinetics during various heterogeneous catalysis reactions [22,23]. Some topological materials were suggested as promising catalysts, for example, Weyl semimetals (Nb, Ta)/(As, P) and MoTe₂ as HER photocatalysts [24], Bi₂Se₃/ZnSe heterostructures [25], Weyl semimetal Co₃Sn₂S [26], Pt-based multifold fermion semimetals [27], and nodal-line semimetal TiSi [28], et al., as HER electrocatalysts. Moreover, the catalytic properties of some topological semimetals were experimentally verified [24,26,27,29]. Among the experimentally tested excellent topological catalysts, we find that topological semimetals have their natural advantage over fully gapped topological insulators, and that can be attributed to the synergistic effect of the metallic bulk states and

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robust TSSs. These promising topological catalytic materials inspire us to optimize the inert basal plane of topological semimetals using the TSSs.

In this study, we make a pioneering exploration of the importance of surface states (SSs) for basal plane HER performance. We find that unlike the binding strength for H adsorption on the inert basal plane of 2H-MoS₂, the topological semimetal Nb₂S₂C basal plane can be improved via the synergistic effect of the $S-3p_z$ orbital-based trivial SSs and S-3 p_x and S-3 p_y -orbital-based nontrivial TSSs, but only to a certain extent, due to the limited $S-3p_z$ SSs in the pristine Nb₂S₂C basal plane. The defective Nb₂S₂C basal plane with Nb-4 d_{r^2} -orbital-dominated TSSs can directly interact with H adsorbate. Besides, the defective Nb₂S₂C presents more Nb- $4d_{xz}$ and Nb- $4d_{x2}$ -orbital-based trivial SSs. Owing to the suitable orbital orientation, they can also provide favourable charge interaction with adsorbed H. Those chemically active orbitals enable energetically and sterically favourable hydrogen adsorption/desorption. Hence, the synergism of the trivial dangling-bonds and TSSs contribute to the greatly optimized ΔG_{H^*} (where the * denotes an active site on the surface and H^* is the reaction intermediate) of 0.31 eV for H adsorption. This study enriches our understanding of the joint effect from dangling bonds and TSSs in the electrocatalytic process and provides a new strategy for the activation of the inert basal plane of catalysts.

2. Computational details

All numerical calculations were performed using the density functional theory (DFT) framework as implemented in the Vienna ab initio simulation package (VASP) [30,31]. The projector augmented wave (PAW) method combined with the Perdew-Burke-Ernzerhof (PBE) generalized gradient approximation were applied [32,33]. The DFT-D3 extension of Grimme was adopted to include the long-range van der Waals (vdW) interactions [34], and Monkhorst–Pack k-point meshes of 8 \times 8 \times 3 and 8 \times 8 \times 1 were used for bulk and pristine Nb₂S₂C slab calculations, respectively. For a surface model, the slab should be thick enough to have a full representation of the surface properties. To confirm the slab thickness, we checked the surface energy dispersion with the increase of the slab thickness (n). As shown in Figure S1, TSSs and trivial SSs present on the slab with n = 3, and they remain unchanged when further increases the slab thickness. In this work, the easily cleaved (001) basal plane was modeled using a 5 unit-cell-thick slab (n = 5) in which the bottom three unit cells were immobilized. To simulate the S-defect, a 3 \times 3 slab model with one S vacancy on the basal plane was constructed, and Monkhorst-Pack kpoint meshes of $3 \times 3 \times 1$ and $6 \times 6 \times 1$ were used for the geometry optimization and electric characteristic calculations. To generate a real space tight-binding model, maximally localized Wannier functions [35] were constructed using the Nb p and d, S p, and C p orbitals. Subsequently, the iterative Green function method was implemented to calculate the SSs of the Nb₂S₂C (001) semi-infinite slab [36].

To simulate the H adsorption process, models in which one H adsorbed on the 1 × 1, 2 × 2 pristine Nb₂S₂C, and 3 × 3 Nb₂S₂C with one S-vacancy supercells were constructed, and those corresponded to the H coverages of 1, 1/4, and 1/9, respectively. To predict the HER activity, the Gibbs free energy of the intermediate state, ΔG_{H^*} , was calculated using the following equations: [3]

$$\Delta G_{(H^*)} = \Delta E_H + \Delta E_{ZPE} - T \Delta S_H \tag{1}$$

where ΔE_H is the H adsorption energy and ΔE_{ZPE} and ΔS_H are the changes in zero-point energy and entropy between the absorbed H and gaseous H, respectively. According to our calculations, ΔG_{H^*} can be obtained as follows:

$$\Delta G_{H^*} = \Delta E_H + 0.27 \text{ eV}$$
⁽²⁾

3. Results and discussion

3.1. Geometric structure and topological electronic properties of Nb_2S_2C

In 2002, Samaki et al. synthesized 1T-Nb₂S₂C for the first time, and determined that it presented trigonal crystal structure with the P $\bar{3}m1$ (164) space group [37]. As illustrated in Figs. 1(a) and (b), Nb₂S₂C crystals present a unique layered structure, in which S-Nb-C-Nb-S quintuple layers are linked to one another in AA stacking via vdW forces. For the Nb-C-Nb layers, each [Nb₆C] octahedron shares six of its twelve edges with adjacent octahedra and the corner Nb atom is shared by three octahedra. The edge linking of [Nb₆C] octahedra is a common structural feature of transition metal carbides, and the vdW interactions between S layers are a typical structural property of transition metal sulfides. The experimentally measured lattice parameters of Nb₂S₂C, which are used for the following calculations, are a = b = 3.269 Å and c = 8.547 Å [37].

The band structures of Nb₂S₂C without and with spin-orbital coupling (SOC) are depicted in Figs. 1(d) and (e), respectively. In the absence of SOC, band inversion occurs between the Nb-4 d_{z^2} , S-3 p_x , and S-3 p_y dominated bands near the Fermi level. With the protection of c_{3z} rotation symmetry, a Dirac point appears owing to band inversion. Once SOC is included, the Dirac point is broken and the band structure of Nb₂S₂C opens a SOC gap at each k-point without band crossings, which enables us to define a Z₂ topological invariant (Fig. 1(e)). By calculating the parities at the time-reversal invariant momenta [38], as shown in Table S1, it is determined that the inverted band gap between bands 19 and 20 form a nontrivial Z₂ index (1;0,0,1) [39–41]. Therefore, TSSs are protected in the inverted band gap. Owing to its layered crystal structure, Nb₂S₂C is a good model for the study of the inert basal plane TSSs-related HER. Scheme 1.

3.2. Gibbs free energies of Nb_2S_2C

After elucidating the topological characteristics of Nb₂S₂C, we focus on its HER activity by directly calculating ΔG_{H^*} , as illustrated in Fig. 2. Firstly, the natural cleavage plane of S-terminated (001) surface is considered for surface catalytic reactions. As depicted in the inset of Fig. 2, under the H coverage of 1, the most energy favorable H adsorption site is the top of S atom with the ΔG_{H^*} calculated to be 1.10 eV. To accurately model the surface HER, especially for the reaction that happens with Volmer–Heyrovsky route, the interfacial solvent effect is also considered to see how it influences the ΔG_{H^*} by using the implicit solvent model implemented in VASPsol with a dielectric constant of 80 [42]. We found that the corresponding ΔG_{H^*} is 1.083 eV, indicating that solvation effects have a negligible influence on the ΔG_{H^*} . Therefore, solvation effect can be ignored in our following calculations. When the H coverage decreased to 1/4, the adsorbed H atom remains at the top of S atom with ΔG_{H^*} slightly decreased to 0.86 eV, indicating the weak bonding strength of H. Because the adjacent layers of Nb₂S₂C are coupled via weak vdW interactions, during the material synthesis, the number of layers can vary greatly. We, therefore, calculate the ΔG_{H^*} for 10 unit-cell-thick slab (n = 10) also to study the effect of slab thickness on the HER performance. At the same H coverage of 1, the ΔG_{H^*} for n = 10 is 1.097 eV, showing a negligible modification compared with that of n = 5 ($\Delta G_{H^*} = 1.10$ eV). It confirms that the HER performance of the material is robust against the slab thickness. Besides, we also explore the possibility of obtaining monolayer (ML) Nb₂S₂C (see details in the Supporting Information) and calculate its ΔG_{H^*} . It's noted that the structure of ML Nb₂S₂C



Fig. 1. (a) Side and (b) top view of the crystal structure of 1T-Nb₂S₂C. The interlayer distance *d* is 2.855 Å, which is the typical vdW distance. (c) Primitive Brillouin zone of Nb₂S₂C. Band structures of Nb₂S₂C (d) without and (e) with spin–orbital coupling. Band inversion occurred between the Nb-4d_{z²}, S-3p_x, and S-3p_y orbitals in the vicinity of the Γ point. The parities of the double degenerate band numbers 19, 20, and 21 are illustrated.

is similar to that of MXenes [43], but quite different from the MXenes which are usually synthesized by selectively etching away the A-element atoms from parent layered ternary or quaternary carbides/nitrides in the solution of HF, giving rise to the mixture of O, OH and F functional groups presented on the basal planes, the ML Nb₂S₂C with ideal homogeneous surface S termination can be obtained by exfoliating from the bulk Nb₂S₂C crystal. Our results indicate that the ML Nb₂S₂C has low cleavage energy (0.42 J/m^2) comparable to MoS₂. Besides, it has high cohesive energy, excellent dynamic stability, and good thermal stability. Hence, it is possible to obtain ML Nb_2S_2C in the experiment. Based on our calculation, the ΔG_{H^*} of ML Nb₂S₂C is 1.01 eV at the H coverage of $\frac{1}{4}$, much smaller than that of 2H-MoS₂, which could be ascribed to the good conductivity presented in the ML Nb₂S₂C. Moreover, it's worth noting that under the same H coverage, the bulk and surface properties of Nb₂S₂C for H adsorption are superior to those of ML Nb₂S₂C and 2H-MoS₂ It indicates that the bulk properties of Nb₂S₂C can benefit for the H adsorption, but only to a certain extent, because the binding strength toward the adsorption of H is still too weak.

Point defects are unavoidable during the material preparation processes. It has been widely recognized that the defects in MoS_2

play an essential role in altering its properties in various ways, and hence, affect its performance [14–16]. Nb₂S₂C has MoS₂-like S-terminated basal plane synthesized by the topo-chemical reaction. In addition, the presence of the TSSs is robust against the defects, impurities and disorders [25,27]. Those all motivate us to study the defective Nb₂S₂C basal plane. To explore the interaction mechanism for TSSs and trivial SSs effects on the HER activity, we consider a small concentration of S-vacancy on the Nb_2S_2C basal plane by creating one S vacancy on the 3×3 Nb₂S₂C basal plane. Based on the formation energy analysis, we find that it is possible to obtain ~11% S-vacancy on Nb₂S₂C. Besides, this S-vacancy site is expected to be preferentially occupied by H other than H₂O molecule under the acidic aqueous conditions (see details in the Supporting Information). We find that the hollow site of three exposed Nb atom becomes the energetically most favorable site for H adsorption as shown in the inset of Fig. 2 and Figure S2 (b), and the ΔG_{H^*} is greatly optimized to 0.31 eV. Due to the broken Nb-S bonds, it induces the formation of local dangling bonds, and therefore, we predict that the combined presence of trivial danglingbond SSs and nontrivial TSSs facilitates the HER at the basal plane, where ΔG_{H^*} is close to 0 eV.



Scheme 1. The synergistic effect between non-trivial topological and trivial surface states provide a new way for activating the basal plane electrocatalytic HER activity, and even for gaining insight into the catalytic mechanism.



Fig. 2. Calculated Gibbs free energy of pristine Nb₂S₂C basal plane with H coverage of 1 and S-vacancy Nb₂S₂C basal plane (S-v Nb₂S₂C). The Gibbs free energy of ML-MoS₂ [44] is also included for comparison. The insets are the side view of optimized atomic structures of Nb₂S₂C and S-v Nb₂S₂C with H atom (black ball) adsorbing on the basal plane. Herein, the thickness of the one-unit-cell is displayed for Nb₂S₂C while their five-unit-cell-thick slabs are used for the calculations.

3.3. Surface properties of pristine Nb_2S_2C basal plane before and after H adsorption

The SSs play an important role in surface catalytic reactions. Both trivial SSs and nontrivial TSSs are present on the Nb₂S₂C basal plane, and their synergistic effects determine the adsorption, desorption, and all kinetic processes on the surface. Nevertheless, the relative magnitude of the effects depends on the specific system. However, compared with the local surface properties of the substrates, the effect of the global properties based on the TSSs on the catalytic activity is often neglected. To understand the mechanism behind the remarkable catalytic activity of Nb₂S₂C, we comprehensively study the surface properties of the Nb₂S₂C basal plane before and after H adsorption.

Owing to topological protection, the TSSs are robust but their shapes are strongly dependent on the details of the environments of the surfaces. As presented in Figs. 3(a) and S5 (a), for pristine Nb₂S₂C basal plane, before H adsorption, the Dirac points associated with the upper-surface TSSs emerge at approximately 0.2 eV below the Fermi level, and are mainly dominated by the S-3 p_x and S-3 p_y orbitals. Furthermore, the partial charge density distribution of the upper-surface TSSs at the Γ point presented in Fig. 3(c) indicates that the TSSs are located on the surface S atoms. Therefore, these findings strongly indicate that the TSSs are distributed on the basal plane, which plays an important role in surface catalytic reactions. Moreover, owing to the weak coupling between the Nb₂S₂C layers, after the creation of the Nb₂S₂C (001) surface, trivial SSs present on the surface. That is confirmed by the presence of some S-3 p_z -orbital-derived density of states near the Fermi level, as il-



Fig. 3. Surface properties of the 1×1 pristine Nb₂S₂C basal plane before and after H adsorption. Surface energy dispersion (a) before and (d) after H adsorption. The red lines indicate the surface states projected from the top one-unit-cell. The bulk projected states are shown in blue as the background. Projected density of states on the surface S atom (b) before and (e) after H adsorption. (c) Partial charge density distribution of pristine Nb₂S₂C at the Γ point within the energy range of -0.2 to -0.1 eV. (f) Charge density difference plot of H adsorbed on the Nb₂S₂C basal plane. The isosurface values are all set to 0.005 e/Å^3 . The thickness of the one-unit-cell is displayed in (c) and (f), and a five-unit-cell-thick slab is used for the calculations.

lustrated in Figs. 3(b) and S5 (a), suggesting the coexistence of the $S-3p_z$ -orbital-derived trivial SSs on the Nb₂S₂C basal plane.

After H adsorption, the chemically active S-3*p* orbitals can interact with the adsorbed H, the S-3*p* orbitals change significantly, the peak of the S-3*p_z* orbitals at the Fermi level disappears, and empty S-3*p_z* orbitals present in the energy range of 1.2–1.8 eV, as demonstrated by the projected density of states in Fig. 3(e) and S-3*p_z*-orbital-weighted band structure in Figure S5 (b). In addition, more occupied S-3*p_x* and S-3*p_y*-orbital-derived states emerge below the Fermi level after H adsorption, and orbital hybridization occurs between the H-1 *s* and S-3*p* orbitals in the energy range of 0–1.7 eV. Moreover, as presented in Fig. 3(f), charges are redistributed; charge accumulation occurs on the adsorbed H atom and S-3*p_x* and S-3*p_y* orbitals, whereas charge is depleted on the S-3*p_z* orbitals. Therefore, the trivial SSs and nontrivial TSSs are directly involved in H adsorption, and that is also confirmed by the orbital-weighted band structure diagrams in Figures S5 and S6.

3.4. Surface properties of pristine Nb_2S_2C and defected Nb_2S_2C before and after H adsorption

After we confirm the crucial role of the synergistic effect of the trivial SSs and nontrivial TSSs during H adsorption, we conclude that the H binding strength on the basal plane of Nb₂S₂C is greatly improved compared with that on 2H-MoS₂, which does not contain S-3 p_z -orbital-derived trivial SSs or nontrivial TSSs on its pristine S-terminated surface. However, the small fraction of trivial SSs and their delocalization caused by the S-3 p_z orbitals of the pristine Nb₂S₂C basal plane limit H binding and facilitate the weak inter-

actions between substrate and H. These findings are reflected in the relatively large ΔG_{H^*} of 1.10 eV and small fraction of charges (0.027 e^-) that transferred from the substrate to the adsorbed H.

With one S vacancy on the 3 \times 3 Nb₂S₂C basal plane, the ΔG_{H^*} is greatly optimized to 0.31 eV. Before the creation of the S vacancy, as shown in Figs. 4(a)-(c) and S7 (a), we find that for the target Nb atom, it is the Nb- $4d_{z^2}$ orbitals that mainly dominate the upper-surface TSS Dirac bands. The Nb- $4d_{2}$ orbital is perpendicular to the basal plane and thus has a suitable orbital orientation for interacting with H 1 s orbital. However, it locates at the sublayer, which prevents overlap between the Nb-4 d_{72} with orbtials of the hydrogen adorbates. When S-vacancy is introduced, this Nb atom is exposed, as shown in Figs. 4(d)-(f) and S7 (b), we find that the upper surface TSS Dirac bands are still mainly dominated by the Nb-4 d_{2} orbitals. Owing to inversion symmetry breaking, upper and bottom TSS Dirac bands are not degenerated anymore. With broken Nb-S bonds on the surface, new bands appear around -0.5 eV below the Fermi level, and these states are mainly dominated by Nb-4 d_{x2} and Nb-4 d_{xz} orbitals. The corresponding partial charge density distribution in Fig. 4(f) indicates that these new states mainly localize around the S-vacancy, and they are responsible for hydrogen adsorption on the S-vacancy. After H adsorption, as shown in Figs. 4(g)-(i), S2 (b), and S7 (c), the H atom prefers to stay at the hollow site of three exposed Nb atoms. Due to the suitable orbital orientation, the chemically active Nb- $4d_{xz}$, Nb- $4d_{xz}$, and Nb-4 d_{r^2} states can interact strongly with the adsorbed H and hybridize strongly with the H-1 s orbitals. Besides, these states change significantly after H adsorption. The charge density differences and Bader charge analysis indicate that the charge accumu-



Fig. 4. Surface properties of 3×3 pristine Nb₂S₂C and 3×3 Nb₂S₂C with one S vacancy before and after H adsorption. Surface energy dispersion of (a) pristine Nb₂S₂C and 11% S-vacancy Nb₂S₂C (d) before and (g) after H adsorption. The red lines indicate the surface states projected from the top one-unit-cell. The bulk projected states are shown in blue as the background. Projected density of states on the same Nb atom (as indicated by the red circle in Figure S2 (b)) for (b) pristine Nb₂S₂C and 11% S-vacancy Nb₂S₂C (e) before and (h) after H adsorption. (c) Partial charge density distribution of pristine Nb₂S₂C at the Γ point within the energy range of -0.2 to -0.1 eV. The isosurface value is set to 5×10^{-5} e/Å³. (i) Charge density distribution of 11% S-vacancy Nb₂S₂C basal plane. The isosurface value is set to 4×10^{-4} e/Å³. (i) Charge density difference plot of H adsorbed on the 11% S-vacancy Nb₂S₂C basal plane. The isosurface value is set to 0.002 e/Å³. (i) Charge density difference plot of H adsorbed on the 11% S-vacancy Nb₂S₂C basal plane. The isosurface value is set to 0.002 e/Å³. (ii) Charge density difference plot of H adsorbed on the three-unit-cells is displayed in (c) and (f), and one-unit-cell is displayed in (i).

lation happens around the adsorbed H with *s* orbital shape, and overall, the H atom acquires a large number of charges of up to 0.471 e^- from the neighboring Nb atoms. Consequently, the H-1 *s* bands disperse in the deep energy region below the Fermi level, as illustrated in Figure S8. The elegant synergistic effect of the robust Nb-4d_{z2}-orbital-dominated TSSs and the Nb-4d_{xz} and Nb-4d_{x2}-orbital-dominated dangling-bond SSs contribute to the greatly optimized Gibbs free energy for electrocatalytic hydrogen evolution.

It worth noting that normally, for topological trivial materials like MoS_2 , by defect engineering, one can create dangling bonds SSs to enhance the adsorbate binding strength. In our work, by introducing the S-defect, we can expose the Nb atom on which the

TSSs located, therefore, we not only have the dangling bonds SSs due to the broken Nb-S bonds but also have the exposed TSSs that can participate in the chemical reaction that happens at the surfaces, they can cooperate with each other to modulate the adsorbate binding strength. The joint utilization of TSSs and dangling bonds SSs opens a new avenue toward activating the basal plane catalytic activity.

4. Conclusions

In conclusion, we demonstrate a highly desirable new strategy for activating the inert basal plane by jointly utilizing the trivial dangling-bond SSs and TSSs of the Nb₂S₂C basal plane. Specifically, bulk Nb₂S₂C is a topological semimetal with the nontrivial Z₂ index of (1; 0,0,1). Upon H adsorption, we determine that the upper-surface TSSs are directly involved in H binding and the TSSs for both the pristine and defective Nb₂S₂C change significantly. For pristine Nb₂S₂C basal plane, the S-3 p_x and S-3 p_y orbital-dominated TSSs act as electron acceptors to modulate the binding strength between the substrate and H, while the $S-3p_z$ orbital-dominated trivial SSs behave as the electron baths for H adsorption. It indicates the equally important contribution of trivial SSs and nontrivial TSSs for surface catalytic reactions. For defective Nb₂S₂C, it exposes the Nb atom on the basal plane and induces more local trivial SSs around Fermi level, hence, the chemically active Nb-4 d_{z^2} -orbital-dominated TSSs and Nb-4 d_{xz} , 4 d_{x^2} -orbitaldominated trivial SSs can interact directly with the adsorbed H. Owing to the synergistic effect of trivial SSs and nontrivial TSSs, the defective Nb₂S₂C basal plane presents greatly optimized activity toward HER with a low $|\Delta G_{H^*}|$ of 0.31 eV. This study provides a promising strategy for the optimization of the electrocatalytic hydrogen evolution activity on the basal-plane of Nb₂S₂C via the synergistic effect of trivial SSs and nontrivial TSSs.

Author contributions

Qun Yang conceived the idea, designed the study, analyzed the data, performed all calculations, and wrote the manuscript. Congcong Le assisted with the theoretical analysis. Guowei Li gave scientific advice. Yan Sun and Thomas Heine modified the manuscript and gave scientific advice. The project was supervised by Claudia Felser. All authors discussed the results and commented on the manuscript.

Declaration of competing interest

The authors declare no competing interests

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Supplementary materials

Supplementary material associated with this article can be found, in the online version, at doi:10.1016/j.apmt.2020.100921.

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